IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Smith, et al.

Docket No.:

2001 P 11900 US01

Serial No.:

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Herewith

Examiner:

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For:

Method of Removing PECVD Residues of Fluorinated Plasma Using In-SITU H2

Plasma

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Dear Sir:

Prior to examination on the merits, Applicants respectfully submit this Preliminary Amendment as set forth below:

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